(19) World Intellectual Property Organization

International Bureau





(43) International Publication Date 9 December 2004 (09.12.2004)

PCT

(10) International Publication Number WO 2004/107045 A3

- (51) International Patent Classification⁷: **B05D 3/10**, B29C 33/00, B32B 31/20, B44C 3/08, C03C 17/30
- (21) International Application Number:

PCT/US2004/016016

- (22) International Filing Date: 21 May 2004 (21.05.2004)
- (25) Filing Language: English
- (26) Publication Language: English
- (30) **Priority Data:**

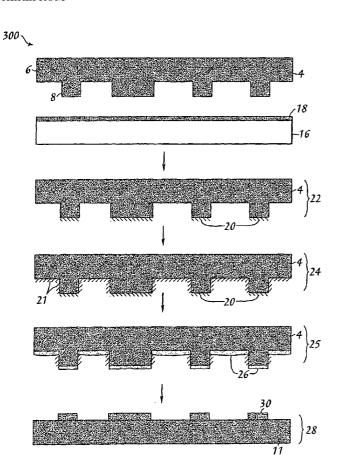
10/444,505 23 May 2003 (23.05.2003)

(71) Applicants (for all designated States except US):
AGENCY FOR SCIENCE, TECHNOLOGY AND
RESEARCH [SG/SG]; 20 Biopolis Way, #07-01, Centros138668, Singapore (SG). THE REGENTS OF THE
UNIVERSITY OF MICHIGAN [US/US]; Ann Arbor,
MI 48109 (US).

- (72) Inventors; and
- (75) Inventors/Applicants (for US only): BAO, Lirong [CN/US]; 2902 Sunny Slope Road, Bridgewater, NJ 08807 (US). TAN, Li [CN/US]; 2376 Stone Road, Ann Arbor, MI 48105 (US). HUANG, Xudong [CN/SG]; Blk 711, Clementi West St. 2, #09-197, Singapore 120711 (SG). KONG, Yen, Peng [MY/SG]; Blk 26, Dover Crescent, #20-61, Singapore 130026 (SG). GUO, Lingjie, Jay [CN/US]; 4910 Ravine Court, Ann Arbor, MI 48105 (US). PANG, Stella, W. [US/US]; 3671 Highlander Way East, Ann Arbor, MI 48108 (US). YEE, Albert [US/SG]; 45 Mt. Sinai Rise, #14-01, Beaverton Court, Singapore 276958 (SG).
- (74) Agents: KORDZIK, Kelly, K. et al.; Winstead Sechrest & Minick P.C., P.O. Box 50784, Dallas, TX 75201 (US).
- (81) Designated States (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN,

[Continued on next page]

(54) Title: METHODS OF CREATING PATTERNS ON SUBSTRATES AND ARTICLES OF MANUFACTURE RESULTING THEREFROM



Methods of creating patterns on (57) Abstract: substrates are presented, and articles of manufacture resulting therefrom. One method comprises applying a first surface energy modifier (18) to an applicator (16) to form a coating on the applicator; contacting the coating (18) with a receiving member (4), the receiving member having a topography, the coating only contacting and remaining on at least some protrusions (8); exposing the first modified receiving member (22) to a second surface energy modifier (21), thereby forming a second modified receiving member (24) having surface modified recesses; applying a composition (26) comprising a polymeric material to the second modified receiving member (24), the composition substantially conforming to the topography of the surface modified protrusion's (8) and the surface modified recesses; and contacting the composition-coated, surface modified protrusions with a substrate (11) for a time and under conditions sufficient to transfer the polymeric material (26) on protrusions to the substrate (11). Because the surface energy of the sidewalls is lower than that on the protrusions, polymer dewetting from the sidewalls is promoted, which makes the polymer film discontinuous along the edges of patterns. Therefore, inked polymer patterns from the protrusions of the mold show very smooth edges and smaller dimensions compared to that of the mold.

WO 2004/107045 A3



CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW.

(84) Designated States (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE, SI,

SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

Published:

- with international search report
- before the expiration of the time limit for amending the claims and to be republished in the event of receipt of amendments
- (88) Date of publication of the international search report: 20 January 2005

For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

INTERNATIONAL SEARCH REPORT

International application No.
PCT/US04/16016

A. CLASSIFICATION OF SUBJECT MATTER IPC(7): B05D 3/10; B29C 33/00; B32B 31/20; B44C 3/08; C03C 17/30 US CL: 156/232,240,247,273.3,289; 427/133,146,402,407.1,444; 264/219; 216/41,49 According to International Patent Classification (IPC) or to both national classification and IPC B. FIELDS SEARCHED Minimum documentation searched (classification system followed by classification symbols) U.S.: 156/232,240,247,273.3,289; 427/133,146,402,407.1,444; 264/219; 216/41,49				
Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched				
Electronic data base consulted during the international search (name of data base and, where practicable, search terms used) Please See Continuation Sheet				
C. DOCUMENTS CONSIDERED TO BE RELEVANT				
Category *	Citation of document, with indication, where ap		Relevant to claim No.	
A,P	US 6,673,287 A (BREEN et al) 06 January 2004 (06	6.01.2004), see entire document,	1-25	
A	especially column 1, line 66 to column 2, line 22. US 6,413,587 A (HAWKER et al) 02 July 2002 (02.07.2002), see entire document, especially Figure 2, column 64 to column 12, line 17.		1-24	
Y A	US 6,380,101 A (BREEN et al) 30 April 2002 (30.04.2002), see entire document especially Figures 1a-1e, column 3, line 34 column 4, line 6. US 6,027,595 A (SULESKI) 22 February 2000 (25.02.2000), see entire document, especially Figure 1, column 5, line 59 to column 6, line 28. US 5,512,131 A (KUMAR et al) 30 April 1996 (30.04.1996), see entire document, especially Figure 1a. US 5,425,848 A (HAISMA et al) 20 June 1995 (25.06.1995), see entire doument, especially		1-24	
Y			25	
X Y			23 and 24 	
A A			1-25 1-25	
	Figure.		1.1	
Further	documents are listed in the continuation of Box C.	See patent family annex.	1:	
Special categories of cited documents:		"T" later document published after the int date and not in conflict with the appli principle or theory underlying the inv	cation but cited to understand the	
of particular relevance "E" earlier application or patent published on or after the international filing date		"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone		
"L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)		"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination		
	t referring to an oral disclosure, use, exhibition or other means	being obvious to a person skilled in the		
"P" document published prior to the international filing date but later than the priority date claimed		"&" document member of the same patent	1.	
10 November 2004 (10.11.2004)		Date of mailing of the international search report 1 DEC 2004		
Name and mailing address of the ISA/US		Authorized officer	- This	
Mail Stop PCT, Attn: ISA/US Commissioner for Patents P.O. Box 1450		Jerry A. Lorengo Telephone No. (571) 272-1700 Fan		
Ale	exandria, Virginia 22313-1450 o. (703) 305-3230	1 Telephione 140. (5/1) 2/2-1/00	· Far	

	International application No.				
INTERNATIONAL SEARCH REPORT	PCT/US04/16016				
•					
•					
Continuation of B. FIELDS SEARCHED Item 3:					
EAST: USPAT, USPGPUB, EPO, JPO, Derwent, IBM-TDB	EAST: USPAT, USPGPUB, EPO, JPO, Derwent, IBM-TDB				
search terms: silane, transfer, transferred, transferable, transferring, stamp, stamp	ed, stamping, mold, mould, microcontact, micro-				
contact, micro, contact, print, printed, printing, hydrophil\$5, hydrophob\$5					